REMARKS

Claims 137-139 and 142-255 remain in the application.

Claims 137, 140 and 142 were indicated to be allowable subject to being rewritten in independent form, and this has been done for claims 137 and 142. Claim 140 has been cancelled because it would have been identical to claim 138 which now depends from allowable claim 137 instead of from withdrawn claim 136. Claim 139 also has been amended to depend from allowable claim 137 instead of from claim 138, and is in condition for allowance.

Claim 145 was indicated to be allowable subject to correcting the misspelling of alkylsilsesquioxane and that has been done.

Claims 143 and 144 were rejected on grounds of double patenting in view of claims 1, 6 and 9 of Serial No. 10/461,967. The Appendix to this paper is a copy of a Preliminary Amendment filed June 13, 2003, simultaneously with the filing of U.S. Serial No. 10/461,967, cancelling claims 1-30 in Serial No. 10/461,967. Therefore, this rejection does not apply.

Claims 137, 138, 139, 142, 143, 144 and 145 are now in condition for allowance.

Claim 146 is similar to allowable claim 143, but with a different definition for RmSiXn.

Claims 147-162 are similar to the allowable claims, but are in a different form and other features are recited in the dependent claims.

Claims 163-255 are similar to cancelled claims 36-136 except that all of claims 163-255 recite an alkylsilsesquioxane polymer film forming substance and do not recite that the product is for use in vapor deposition.

All of claims 137-139 and 142-255 are directed to the elected invention.

This application is now in condition for allowance.

Respectfully submitted,

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